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Nondestructive Mapping of Long-Range Dislocation Strain Fields in an Epitaxial Complex Metal Oxide

Hugh Simons,^{*,†}[®] Anders Clemen Jakobsen,[†] Sonja Rosenlund Ahl,[†] Henning Friis Poulsen,[†] Wolfgang Pantleon,[‡] Ying-Hao Chu,[§][®] Carsten Detlefs,[∥] and Nagarajan Valanoor[⊥][®]

[†]Department of Physics, Technical University of Denmark, Kgs. Lyngby 2800, Denmark

[‡]Department of Mechanical Engineering, Technical University of Denmark, Kgs. Lyngby 2800, Denmark

[§]Department of Materials Science & Engineering, National Chiao Tung University, Hsinchu 30010, Taiwan

^{II}European Synchrotron Radiation Facility, 71 Avenue des Martyrs, 38043 Grenoble Cedex 9 France

 $^{\perp}$ School of Materials Science & Engineering, University of New South Wales, Kensington 2052, Australia

ABSTRACT: The misfit dislocations formed at heteroepitaxial interfaces create long-ranging strain fields in addition to the epitaxial strain. For systems with strong lattice coupling, such as ferroic oxides, this results in unpredictable and potentially debilitating functionality and device performance. In this work, we use dark-field X-ray microscopy to map the lattice distortions around misfit dislocations in an epitaxial film of bismuth ferrite (BiFeO₃), a wellknown multiferroic. We demonstrate the ability to precisely quantify weak, long-ranging strain fields and their associated symmetry



lowering without modifying the mechanical state of the film. We isolate the screw and edge components of the individual dislocations and show how they result in weak charge heterogeneities via flexoelectric coupling. We show that even systems with small lattice mismatches and additional mechanisms of stress relief (such as mechanical twinning) may still give rise to measurable charge and strain heterogeneities that extend over mesoscopic length scales. This sets more stringent physical limitations on device size, dislocation density, and the achievable degree of lattice mismatch in epitaxial systems.

KEYWORDS: Ferroelectric, dislocation, BiFeO3, strain, microscopy, diffraction

s semiconductor and complex metal oxide nanoelec-Atronics employ increasingly aggressive strain-engineering strategies, a comprehensive understanding of the functional consequences of atomic-scale defects has never been more important.¹ In particular, dislocations undermine straininduced phenomena by altering local chemistry at the dislocation core² and relaxing imposed epitaxial strain;³ even single dislocations create long-range strain fields that significantly compromise the electronic structure⁴ and physio-chemical nature of the material.⁵

Comprehensively understanding the collective influence of defects such as dislocations requires precise, quantitative, and spatially resolved measurements of the lattice distortions they create. For many years, the main approaches were dark-field electron microscopy⁶ and X-ray topography,⁷ in which Bragg diffraction provided great sensitivity to lattice distortions through the intensity fringes surrounding the dislocation(s). These fringes often persist over several micrometers from the dislocation core, demonstrating the presence of elastic interactions over mesoscopic distances. However, the complexity of the dynamical scattering process responsible for the fringes made quantitative and unambiguous determination of the strain fields and lattice symmetry challenging, if not impossible. The more recent development of atomic resolution scanning transmission electron microscopy (STEM) now

enables strain and symmetry to be mapped directly from the atomic displacements.⁸ This approach is intuitive and direct; however, (1) the field-of-view is restricted to only tens of unit cells (i.e., nanoscale) around the dislocation core; (2) the strain resolution ($\sim 10^{-3}$) is insufficient to detect elastic strain fields slightly beyond the dislocation cores;⁹ and (3) samples must be thin (20-30 nm) cross sections, meaning the lateral (i.e., in-plane) mechanical constraints are very different from those of the macroscopic film.

The capability to measure weak strain fields (i.e., well below 10^{-3}) over mesoscopic scales without perturbing the mechanical state of the material (i.e., nondestructively) has recently become available with the development of dark-field X-ray microscopy.¹⁰ The technique combines sub-100 nm spatial resolution with a 400 \times 200 μ m² field of view and sensitivity to small structural distortions of the order of 10⁻⁵.¹¹ Like its electron-based analogue, dark-field X-ray microscopy uses an X-ray objective lens in the Bragg-diffracted X-ray beam to create a magnified image of the sample corresponding to a restricted and known volume in reciprocal space.¹² It requires similar instrumentation to X-ray diffraction topography¹³ and

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Figure 1. Multiscale diffraction measurements on the BiFeO₃/SrRuO₃/DyScO₃ film. The three types of measurement (a) comprised 3D reciprocal space maps (i.e., diffraction) using a 2D detector with moderate resolution (54 μ m) far from the sample, large field-of-view maps of the dislocation distribution (i.e., X-ray topography) using a high-resolution detector close to the sample, and high-resolution orientation/inclination and elastic strain maps (i.e., dark-field X-ray microscopy) using a magnifying lens between the sample and a high-resolution detector. The resulting diffracted intensity distribution around the 002 reflection (b) shows peak broadening from dislocations and lobes from the ferroelectric domain structure (note that intensity is shown on a logarithmic scale). X-ray topography map (c) showing the coarse-scale distribution of the dislocations, which can be seen in individual detail in (d) the dark-field X-ray microscopy image. All diffraction measurements were carried out on the 002 reflection with an X-ray energy of 17 keV at ID06 of the European Synchrotron Radiation Facility.



Figure 2. Dark-field microscopy maps of the BiFeO₃ film around the 002 Bragg reflection. (a) Out-of-plane lattice strain ε_{33} , (b) close-up of the strain fields due to individual dislocations, and (c) strain profile through the black line in (b). The local lattice plane inclination of the same region (d) and corresponding close-up (e) are colored according to the key (right), which is superimposed with a contour map of the diffraction intensity of the entire map. Corresponding profiles of the lattice tilt components (χ , ϕ) are additionally shown in (f). Note that the red region to the right of (a) is a scratch in the film surface and is not considered in this (or subsequent) analysis.

X-ray reciprocal space mapping¹⁴ (Figure 1a), allowing it to be carried out in conjunction with these techniques in quick succession to intuitively create a multiscale picture of the structure and topology (Figure 1b-d). Crucially, this combination of a large sample size, nondestructive measurements, and exceptional angular resolution presents opportunities for new types of measurement not previously possible.

Here, we apply dark-field X-ray microscopy to quantify the long-range structural distortion fields (elastic axial strain and lattice plane inclination) around individual dislocations in an epitaxial film of bismuth ferrite (BiFeO₃). BiFeO₃ is an important model system for oxide nanoelectronics and a

single-phase room-temperature multiferroic exhibiting three strain-coupled functional responses, namely, ferroelectricity, ferroelasticity, and antiferromagnetism. Furthermore, BiFeO₃ exhibits defect-driven phenomena (e.g., memristivity,¹⁵ domain-wall conductivity,¹⁶ and photoelectricity¹⁷) believed to be susceptible to heterogeneous strain. Lowering the nominal symmetry through strain engineering and heteroepitaxy is a well-known way to induce new or radically modified functionality,¹⁸ but understanding the physical consequences of these symmetry-breaking distortions first requires identifying their origin and quantifying their effect on the local structure. The ability to provide a clear description of the



Figure 3. Maps of the resolvable components of the dislocation density tensor. The α_{31} (a, b) and α_{32} (c, d) components reflect edge dislocation densities, while the α_{33} (e, f) component represents screw dislocation density. The sign of the density corresponds to the sign of the edge components or the chirality of the screw dislocations. Correlated edge and screw densities are highlighted by the diagonal box on panels (b), (d), and (f). Note that α_{ik} has undergone a coordinate transformation corresponding to a rotation by 45° around the film normal such that the axis x_1 and x_2 for α_{31} and α_{32} are parallel to the [100] and [010] directions, respectively.

consequences of dislocations in BiFeO₃, and in particular their long-range strain fields, would catalyze a new understanding of how these dislocations relax the epitaxial strain, as well as how long-range strains influence critical parameters in complex metal oxides.

The sample used here was a 120 nm thick film of <001>oriented BiFeO₃, grown via pulsed laser deposition on a SrRuO₃ electrode layer and <110>-oriented DyScO₃ single crystalline substrate (note all Miller indices are indexed as $Pm\overline{3}m$). The film had highly periodic, <111>-polarized stripe domains with an average width of 0.2 μ m and domain walls along [110] directions (see Methods and ref 19 for details). As in other <001>-oriented perovskites, dislocations are expected to have Burgers vectors with out-of-plane components, such as along [101] or [011] directions.^{20–23} The X-ray measurements carried out for this work utilized the specular 002 reflection, meaning that structural contrast arose only from out-of-plane atomic displacements. This implies that the lattice distortions from <111>-polarized domains and 110-oriented domain walls should be weak in comparison to other sources of symmetrybreaking distortions, such as dislocations.²⁴ Shown in Figure 1b, the X-ray reciprocal space map around the 002 reflection of the BiFeO₃ shows clear evidence of these symmetry-breaking lattice distortions in the film, i.e., four lobes of increased intensity at small angles from the main peak classically

associated with lattice rotations across the ferroelastic <110>-oriented domain walls²⁵ and diffuse intensity surrounding the main peak attributable to symmetry breaking by dislocations²⁶ or non-Ising domain walls.²⁷ Finely mottled intensity contrast in the X-ray topography image (Figure 1c) suggests that local structural defects are distributed across the entire film. Using dark-field X-ray microscopy to magnify this mottled intensity contrast (Figure 1d) reveals no evidence of domain walls (as expected from the 002 reflection) but sharp points of intensity variation consistent with individual dislocations.²⁶

Figure 2 shows maps of the axial strain ε_{33} and the lattice plane inclination (χ , ϕ ; see Figure 1a for schematic) for a 200 × 400 μ m² region of interest near the center of the sample obtained by dark-field X-ray microscopy. The strain and inclination variations are correlated, as elongated lobes of positive and negative strain in (b) correspond to sharp changes in inclination in (d). Note that the strain lobes in Figure 2b and 2c typically extend 1–8 μ m in [100] and [010] directions and in some cases mutually superimpose.

The quantitative measurement of lattice distortions over such a large spatial range, i.e., several micrometers, is a key result. In this manner, we can quantify the long-ranging strain fields and unambiguously demonstrate that the observed distortions locally break the nominal rhombohedral symmetry

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Figure 4. Flexoelectric polarization contributions. Magnitude and orientation over the BiFeO₃ film surface and close-up (a, b), where orientation and magnitude of the polarization component are given by hue and lightness, respectively. The perimeter of the colorwheel corresponds to a polarization magnitude of 0.40 μ C/cm², while the maximum value in the image was 1.42 μ C/cm². A further close-up of the polarization augmentation around a single dislocation (c) which shows head-to-head polarization toward the core, resulting in a net electrical charge at the dislocation core. The polarization magnitude in (c) is given in units of μ C/cm² and is calculated assuming a flexoelectric coefficient of $\mu = 1.4 \mu$ C/m (from ref 39).

(space group R3c). The quantitative nature of the lattice strain and inclination maps allow the type, size, positions, and directions of the individual dislocations to be determined. As we probe the <001>-oriented BiFeO₃ film with the 002 scattering vector, Q_{002} , the measurements describe the lattice perturbations generated by dislocations with parallel, out-ofplane components to their Burgers vector. Dislocations with both edge and screw characteristics contribute to these distortions, and can be described by the local dislocation density tensor²⁸ $\alpha_{ik} = \sum_{t=1}^{N} b_i^t l_k^t \rho^t = -\epsilon_{klj} \frac{\partial \beta_{ij}}{\partial x_l}$ originating from the individual dislocation densities ρ^t of all different dislocation types t, each characterized by their Burgers vector b_i^t and line vector l_{k}^{t} . Alternatively, the components of dislocation density tensor can be found as gradients of the elastic distortion tensor β_{ij} with respect to the spatial dimension x_l via the Levi-Civita permutation symbol $\epsilon_{klj'}^{29}$ In turn, the elastic distortion tensor β_{ij} is linked to the elastic strain tensor ε_{ij} and the lattice rotations. From the nine components of the dislocation tensor α_{ik} , three components are resolvable from the maps of ε_{33} (i.e., out-of-plane) strain and the ϕ and χ lattice inclinations:

$$\alpha_{31} = -\frac{\Delta\beta_{33}}{\Delta x_2} = -\frac{\Delta\varepsilon_{33}}{\Delta y}$$
(1a)

$$\alpha_{32} = \frac{\Delta\beta_{33}}{\Delta x_1} = \frac{\Delta\varepsilon_{33}}{\Delta x}$$
(1b)

$$\alpha_{33} = -\left(\frac{\Delta\beta_{32}}{\Delta x_1} - \frac{\Delta\beta_{31}}{\Delta x_2}\right) = -\left(\frac{\Delta\varphi}{\Delta y} + \frac{\Delta\chi}{\Delta x}\right) \tag{1c}$$

The differences in the symmetry of the elastic distortion fields generated by dislocations of different character (i.e., screw or edge) mean that different components of α_{ik} represent dislocation densities of different character, i.e., the α_{31} and α_{32} components correspond to the local density of edge dislocations, while the α_{33} component corresponds to the local density of screw dislocations.³⁰

In Figure 3, maps of α_{31} , α_{32} , and α_{33} show the densities of dislocations in the BiFeO₃ film with edge and screw character and an out-of-plane component of the Burgers vector. The α_{31} and α_{32} maps reveal similarly elongated features as the strain maps and profiles in Figure 2, suggesting edge dislocation lines spanning over several micrometers. The α_{33} map, however, shows points of large positive or negative dislocation density,

predominantly in pairs. Their magnitude, which is typically in the order of 2×10^{-4} nm⁻¹, is comparable to the estimated value for a single screw dislocation within a pixel $(b/\Delta x \Delta y =$ 2.5×10^{-4} nm⁻¹ for a length of the Burgers vector *b* of the order of the lattice parameter, *a*), suggesting each pixel contains a single threading dislocation with a partial screw character. In addition, the difference in the chirality between two connecting threading dislocation is reflected in the opposite sign of the dislocation density α_{33} .

A clear picture now emerges of the mesoscale strain fields generated by dislocations. In several places, the dislocation density maps conform to the classical perception for a misfit dislocation in which an edge dislocation with a line direction parallel to the film-substrate interface is terminated by a pair of right- and left-handed screw dislocations, albeit here with out-of-plane components of the Burgers vectors rather than the common in-plane component. In Figure 3, such connecting edge dislocations are suggested by the elongated features along [100] and [010] directions in (3b and 3d) traversing between α_{33} components of opposite sign (3f), i.e., screws of the same Burgers vector with opposite chirality. We note that, in principle, it is possible to determine the sign of the Burgers vector of the misfit dislocation from the chiralities of a given pair of screw components. This information would be particularly valuable in assessing the effectiveness of the misfit dislocations at relaxing the epitaxial strain. However, the relevant component of the Burgers vector for this relaxation will be in-plane and is not accessible by imaging the out-ofplane lattice distortions as per the measurement configuration used here. Only imaging a Bragg reflection with an in-plane component (e.g., 110 or 111) would reveal the complementary relaxation mechanisms of both the ferroelastic stripe domains and the misfit dislocations. In fact, the faint periodic contrast in the images is an artifact arising from aliasing of small lattice rotations from ferroelectric domain walls, which have a similar periodicity to the spatial resolution of the instrument. The interactions of these domains directly with the misfit dislocations cannot be clearly established here; however, piezoresponse force microscopy (PFM) images of this sample¹⁹ show domains terminating at line defects with similar spacing and attributes as the dislocation described here.

Having established that the long-range lattice distortion fields observed here (and shown in Figure 2) originate from dislocations (as revealed by their densities in Figure 3), we now consider the impact of these mesoscale strain fields on the local ferroelectric properties. Because dislocations break the R3c crystal symmetry, so too do their ensuing strain fields. This has two implications: (1) extrinsic strains that cant the polarization vector may permit polarization rotation mechanisms, which are known to impact dynamic dielectric and piezoelectric properties significantly,³¹ and (2), the distortion fields can directly contribute to the static polarization through the flexoelectric effect.³²

Flexoelectricity is a linear coupling between polarization and the elastic distortion gradient via the flexoelectric coupling coefficient μ : $P_l = \mu_{lijk} \frac{\partial \beta_{ij}}{\partial x_k}$.³² The effect occurs in all insulating crystals and is shown to influence a range of phenomena including localized photoelectricity,¹⁷ polarization rotation at domain walls,³³ and measurable piezoelectricity above the Curie temperature, T_{c} .³⁴ To date, most studies of flexoelectricity in ferroic materials have focused on the strain fields generated by domain walls, which decay exponentially with distance from the wall.³⁵ In comparison, however, dislocations have a slower, hyperbolic decay of the distortion fields³⁶ that should result in flexoelectric effects over much longer distances than that of domain walls. Surprisingly, the flexoelectric effect due to dislocations in a ferroelectric matrix has not garnered the same level of interest as domain walls in ferroelectric materials, despite the long-ranging strain gradients being significantly larger than those associated with ferroelastic domain walls.

Figure 4 shows this long-range flexoelectric polarization contributions clearly; the in-plane flexoelectric polarization P_i (i.e., its magnitude and direction) is derived from direct measurements of the out-of-plane strain gradient assuming $\mu_{133k} = \mu \delta_{lk}$ (note the formulation of the flexoelectric polarization in terms of elastic strain gradients^{37,38} is only justified for compatible elastic distortion fields; as the distortion field around dislocation cores itself is locally incompatible, the above formulation based on the elastic distortion tensor β_{ij} has to be used). The magnitude of the polarization |P| is enhanced in the vicinity of the edge dislocations detected in Figure 3 and remains measurable up to a few micrometers from the perceived dislocation core (Figure 4b). Furthermore, the flexoelectrically induced polarization is canted toward the dislocation core in a head-to-head arrangement, resulting in a net charge (Figure 4c). Similarly, dislocations whose edge components have opposite signs result in tail-to-tail configurations and a localized net charge of opposite sign. In the absence of an accepted theoretical value of the flexoelectric coefficient for rhombohedral BiFeO₃, our calculations of the magnitude of the flexoelectric polarization used the experimentally determined value for M1 phase BiFeO₃ of $\mu = 1.4 \ \mu C/m$.³⁹ This would suggest long-ranging polarization contributions up to 1.4 C/cm^2 ; however, we note that the real value may be lower, as the experimentally determined flexoelectric coefficient is approximately 3 orders of magnitude larger than the accepted values for other oxide perovskites (e.g., $SrTiO_3$).⁴⁰ It is therefore difficult to precisely ascertain the significance of this flexoelectric contribution. However, it is conceivable that even the presence of very small charge fluctuations across the film will give rise to screening behavior, either by the domain structure via curved or otherwise charged domain walls, or by free carriers and vacancies, which should be abundant in BiFeO₃. This may then have indirect influences upon the local depolarization behavior 41 and defect chemistry 42

These results demonstrate dark-field X-ray microscopy as a new probe for quantitatively and nondestructively mapping of small structural distortions over mesoscale distances. Our results show how strain fields of dislocations also affect the mesoscale structure and polarization, with distinct deviations from the nominal lattice symmetry across the majority of the sample and heterogeneous polarization perturbations due to flexoelectricity. Combined with atomic resolution microscopy studies of the chemical and functional properties in the immediate vicinity of the cores, we are now in a position to genuinely quantify the lattice-functional response across four orders of magnitude in length. This is a major step toward the development of computational materials engineering approaches⁴³ through the validation of multiscale models that predict how individual defects influence macroscopic structure and properties. The mesoscale structural and functional perturbations we measure here are small; however, given the sensitivity of nanoelectronic devices to small changes in electronic structure and local crystallography, it is plausible that dislocations, and our ability to fully characterize them, will have appreciable consequences across a broad spectrum of materials and devices.

Methods. Sample Preparation. A detailed description of the sample manufacture is provided in ref 19.

X-Ray Configuration. All X-ray measurements were carried out on the hard X-ray microscope at the beamline ID06 of the European Synchrotron Radiation Facility (ESRF). An X-ray energy of 17 keV was used, with a bandwidth of 10^{-5} (rms) selected by a Si 111 double monochromator. A Be transfocator 30 m from the undulator prefocused the X-rays onto the sample, which was located 10 m further downstream. The beam profile at the focal point was approximately Gaussian, with dimensions of 200 μ m (horizontal) × 50 μ m (vertical), confirmed by direct imaging with a CCD camera. The sample was positioned such that the beam entered the sample at the approximate center of the 5 × 5 mm² face when tilted in the Bragg condition for the 002 reflection (i.e., $\theta + \phi = 11.3^{\circ}$ and $2\theta = 22.6^{\circ}$). Indirect 2D detectors composed of a scintillator, visible optics, and CCD camera were used.

Reciprocal Space Mapping. Reciprocal space maps used a Basler CCD camera, 12 mm f/1.4 machine vision optics, and a plastic scintillator with a ϕ 50 mm circular field of view with 54 μ m pixels. This field of view acquires approximately 2.22° in χ and 0.55° in 2 θ in each image. Exposures of 1 s were recorded while incrementally tilting the ϕ angle through 0.6° in 500 steps. These image series were then computationally interpolated into linear $\phi - \chi - 2\theta$ space.

X-Ray Topography. These measurements used a FReLoN CCD detector with a 2048 × 2048 array of 0.622 × 0.622 μ m pixels positioned 5 mm from the sample. A series of 500 images were measured with 0.3 s exposures while tilting ϕ from -0.1° to 0.1° .

Dark-Field X-Ray Microscopy. Dark-field X-ray microscopy measurements required inserting an X-ray objective lens and a higher-resolution CCD camera into the diffracted beam path. The X-ray objective comprised a Be compound refractive lens with a focal length of 25 cm, which gave an X-ray magnification of 15.9x at a numerical aperture of 5×10^{-4} . The FReLoN CCD camera used a LAG scintillator and a 10x microscope objective, yielding an effective pixel size of 1.4 μ m. Combined, the dark-field microscope had a spatial resolution of approximately 82 nm (vertical) \times 420 nm (horizontal). Image acquisition consisted of recording a 3 s exposure as the sample was progressively tilted through χ and ϕ , and the objective and were detector tilted through 2θ in 20 steps over 1° per direction. Details can be found in refs 10 and 12.

AUTHOR INFORMATION

Corresponding Author

*E-mail: husimo@fysik.dtu.dk.

ORCID 💿

Hugh Simons: 0000-0002-3093-9241 Ying-Hao Chu: 0000-0002-3435-9084 Nagarajan Valanoor: 0000-0003-2534-5868

Author Contributions

Y.H.C. grew the sample. H.S. carried out the measurement with assistance from A.C.J. and S.R.A. H.S. analyzed the data and then interpreted it with N.V. and W.P. H.S. wrote the manuscript with input from N.V., W.P., C.D., and H.F.P.

Notes

The authors declare no competing financial interest.

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